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Reply dated May 5, 2010

Reply to Office Action of February 05, 2010

AMENDMENTS TO THE CLAIMS

1. (Currently Amended) A method for forming a pattern, comprising:

providing a substrate on which a plurality of unit panels and etching object layers on the

respective unit panel areas are formed, each of the unit panels including a plurality of gate lines

and data lines defining a plurality of pixels, a thin film transistor in each pixel, and a pixel

electrode in each pixel;

providing a cliché on which a plurality of grooves are formed, the cliché being divided

into a plurality of portions corresponding to the unit panels of the substrate;

filling resist in the grooves;

transferring the resist in the grooves of one divided portion of the cliché on a blanket

applied on a surface of a printing roll by contacting and rotating the printing roll with one

divided portion of the cliché, the printing roll corresponding to the respective unit panel of the

substrate, the circumference area of the printing roll corresponding to the area of one unit panel;

applying the resist transferred on the surface of the blanket of the printing roll on the

etching object layer on a corresponding unit panel of the substrate; and

repeating the transferring process and applying process to the etching object layer on other unit

panels of the substrate from other divided portions of the cliché using the printing roll

transferring the resist in the grooves of other divided portion of the cliché on a blanket applied on

the surface of the printing roll by contacting and rotating the printing roll with other divided

portion of the cliché; and

applying the resist transferred on the surface of the blanket of the printing roll on the

etching object layer on a corresponding unit panel of the substrate.

2. (Previously Presented) The method of claim 1, wherein the printing roll has a same

width as that of the corresponding unit panel of the substrate.

Claim 3 (Cancelled)

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4. (Previously Presented) The method of claim 2, wherein a length of the blanket of the

printing roll is the same as a length of a circumference of the printing roll, which is same as a

length of the unit panel of the substrate.

Claims 5-6 (Cancelled)

7. (Previously Presented) The method of claim 1, wherein the printing roll is formed to

have a same size as that of the unit panel the substrate.

8. (Original) The method of claim 1, wherein the etching object layer includes a metal

layer.

9. (Original) The method of claim 1, wherein the etching object layer includes an

insulating layer comprised of SiOx or SiNx.

10. (Original) The method of claim 1, wherein the etching object layer is a semiconductor

layer.

Claims 11-27 (Cancelled)

28. (Previously Presented) The method of claim 1, wherein the blanket improves

adhesive force with the resist.

Claims 29-34 (Cancelled)

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